



Wave and Particle in Molecular Interference Lithography

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The wave-particle duality of massive objects is a cornerstone of quantum physics and a key property of many modern tools such as electron microscopy, neutron diffraction or atom interferometry. Here we report on the first experimental demonstration of quantum interference lithography with complex molecules. Molecular matter-wave interference patterns are deposited onto a reconstructed Si(111) 7×7 surface and imaged using scanning tunneling microscopy. Thereby both the particle and the quantum wave character of the molecules can be visualized in one and the same image. This new approach to nanolithography therefore also represents a sensitive new detection scheme for quantum interference experiments.

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The de Broglie wave nature of massive particles has always been an essential ingredient in the conceptual development of quantum mechanics [1,2]. First demonstrations of the electron wave nature [3,4] were soon followed by experiments on the diffraction of helium atoms and H₂ molecules [5] as well as neutrons [6,7]. The buildup of quantum interference patterns from single particles was shown in particularly nice demonstrations with individual photons [8] and electrons [9,10]. With the availability of laser and nanofabrication technologies, atom interferometry and coherent lithography have become rapidly developing fields of research [11–14]. Recently, quantum interference experiments have also been extended to composite nanoparticles, such as fullerenes [15], He clusters [16] or large fluorinated molecules [17,18].

Our present demonstration complements these earlier studies as it represents the first realization of quantum interference lithography with molecules. It thereby closes two gaps that so far existed in the field of macromolecule interferometry: On the one hand, previous experiments had not been able to visualize the individual particles that traversed the interferometer. Further, it has also been discussed by several authors that ionizing detectors are inefficient already for medium-sized organic materials [19,20]. Being sensitive to single molecules, our new lithographic interference detection scheme provides, for the first time, the opportunity to visualize both the quantum wave features and the composite particle nature of individual molecules in one and the same image and experiment. On the other hand, we show that near-field interferometry is a very natural approach to generating surface-deposited and immobilized nanopatterns with particles that can, in principle, be regarded as functional entities by themselves. Our experiment thus operates at the interface between matter-wave interferometry and surface nanoscience.

A schematic illustration of the setup is shown in Fig. 1. The experiment is sectioned into five differentially pumped vacuum chambers, which comprise three logical compartments: the source, the interferometric nanodeposition and the detector. The supplementary vacuum chambers are required for differential pumping as well as for the preparation and transfer of the detection surface. A Knudsen cell at $T = 1070$ K forms the molecular beam which is se-

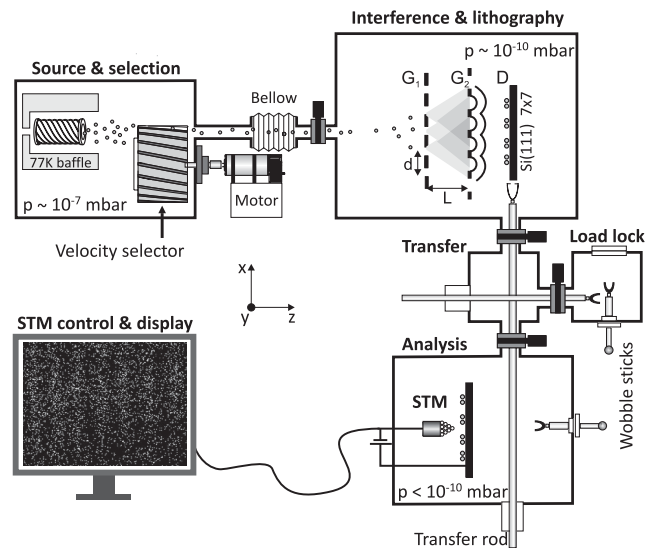


FIG. 1. Molecular interference lithography combines coherent molecule wave propagation with surface deposition and scanning probe microscopy. The furnace emits a thermal fullerene beam, velocity selected to $\Delta v/v = 5\%$, which passes two SiN gratings ($d = 257.40$ nm) separated by $L = 12.5$ mm. A prepared silicon sample is placed in distance L behind G_2 . The molecular deposit is imaged with single molecule resolution using scanning tunneling microscopy in a separate UHV chamber.

lected within a transmitted velocity band of $\Delta v/v = 0.05$ (FWHM) to account for the fact that different velocities correspond to different de Broglie wavelengths, $\lambda_{dB} = h/mv$, and to varying interaction times with the gratings.

Two alternative methods have been used for selecting the molecular speed: First, a gravitational velocity selection scheme exploits the molecular free-fall trajectories in the Earth's gravitational field. This established method [21,22] allows to work without any vibrating or rotating element. The interference fringe contrast of the molecular deposit varies, however, with the vertical position on the sample and scattering at the slit edges may spoil the selection quality.

Second, interferograms were also recorded using a home-built helical velocity selector which is a miniaturized version of devices known from neutron scattering [23]. Grooves of 300 μm width were milled along helical trajectories into an aluminum cup of 40 mm length. The aspect ratio of length and width of the grooves defines the transmitted velocity bandwidth. Their pitch and angular speed defines the center of the distribution. The selector is held by UHV compatible bearings and driven by a motor outside of the chamber. A magneto-fluidic seal allows the mechanical transduction of the rotational motion at frequencies in excess of 100 Hz. An acceleration sensor at the mechanical base of the interferometer quantified typical oscillation amplitudes to be as small as 2 nm.

This method was chosen for the experiment presented here. Its advantage lies in the fact that all transmitted particles arrive with the same speed and the nanostructure has the same contrast across the entire surface that is illuminated by the molecular beam. Being independent of gravitation the selection scheme can be used in any orientation of the experiment.

About 110 cm behind the source, the molecules encounter the first diffraction grating G_1 of a near-field interferometer [22,24,25]. Diffraction at each of the individual slits within G_1 expands the molecular coherence function to an extent that it covers several slits of the second grating G_2 . Diffraction at G_2 , coherent evolution and interference subsequently generate a molecular density pattern, which we accumulate on the detector screen D .

The SiN_x gratings were fabricated by Dr. Savas at MIT, Cambridge [26] with a highly accurate period of $d = 257.40(1)$ nm and with open slit windows as small as 75 nm in G_1 and 150 nm in G_2 . In our symmetrical setup, the separation L between the two gratings is equal to the distance between G_2 and D . The molecular distribution on the detector is then an approximate self-image of the transmission function of G_2 , if the Talbot condition is met, i.e., if $L = d^2/\lambda_{dB}$ in the absence of any external potentials. Although the nanomechanical gratings are fabricated with a rectangular transmission profile, interference and phase shifts in the gratings lead to a near-sinusoidal molecular density pattern on the screen. The fringe visibility can then

be extracted as $V = (S_{\max} - S_{\min})/(S_{\max} + S_{\min})$, where $S(x)$ is the local molecular surface density at position x .

The detector screen is a thermally reconstructed Si(111) 7×7 surface. Silicon is known to capture and bind fullerenes exceptionally well [27] and it is also the natural choice for interfacing molecular deposits to future electronic readout or control. The atomically clean and flat surface immobilizes the incident molecules and it allows us to operate the experiment at room temperature. It requires, however, a proper surface cleaning, preheating and flash-heating in the readout chamber which also contains the variable temperature scanning tunneling microscope (RHK STM UHV 700).

For a grating separation of $L = 13.2$ mm we expect the maximum interference contrast of the first Talbot order for a de Broglie wavelength of 5 pm, i.e., for C_{60} with a mean velocity of 111 m/s. The van der Waals interaction between the molecule and the grating wall reduces the effective grating opening and shifts the theoretical fringe visibility. At a mean molecular velocity of $v = 115$ m/s we expect a maximum contrast of about $V = 60\%$. If the molecules were classical billiard balls, i.e., following trajectories of Newtonian physics, theory would predict a nearly flat molecular distribution at the detector, i.e., a vanishing fringe visibility of only $V = 1\%$. This comparison of visibilities underlines the importance of the molecular quantum wave nature for the emergence of high-contrast patterns in this kind of lithography.

The total experimental sequence is as follows: A silicon surface is thermally reconstructed, characterized in the STM and then transferred into the interferometer. The angular frequency of the helical velocity selector is set to transmit the velocity class $v = 115 \pm 5$ m/s. The molecular exposure lasts about 30 min and we deposit about 0.001 molecular monolayers (ML) on the target. This low coverage is required to maintain the single-particle character in the quantum demonstration. The exposed sample is then transferred into the detector chamber.

The STM surface scan of Fig. 2 clearly reveals the individual silicon substrate atoms as well as several immobilized single C_{60} molecules. The surface binding of the fullerenes is so strong that we could not observe any clustering, even over two weeks. High-resolution tunneling microscopy at low temperatures even allows us to get a glimpse on the *internal* structure of the deposited fullerenes [28], as shown in the inset of Fig. 2.

In order to see the interference pattern we probe an area of $2 \mu\text{m}^2$ at a resolution that still allows to identify the individual molecules. This scan takes about 30 min and returns 10^6 data points. We identify the molecules by their height: if a recorded pixel (i, j) is 0.5–0.9 nm higher than the average of the neighboring pixels $(i \pm 3, j \pm 3)$ it is identified as a fullerene molecule. The analog images are thus converted into a binary matrix, where the presence of a molecule is represented by the digit one, whereas all

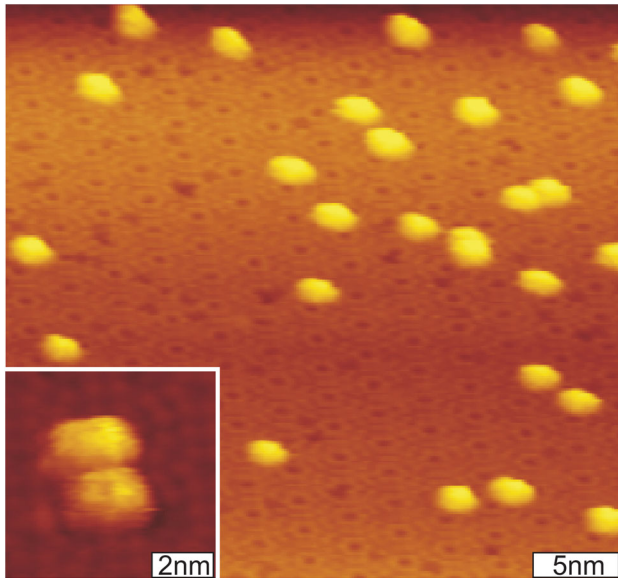


FIG. 2 (color). STM image of a reconstructed Si (111) 7×7 surface, covered with immobilized individual fullerenes. Area of this image: $33 \times 36 \text{ nm}^2$; tunneling current $I = 0.2 \text{ nA}$; sample bias voltage $U = +2 \text{ V}$; temperature $T = 30 \text{ K}$. A close up on two fullerenes (see inset) gives a glimpse on the internal ring structure of C_{60} (see also [28]).

other pixels are set to zero. The result of this procedure is shown in Fig. 3(a), where the bright dots represent the molecules. For a better visualization, the pixels were later binned in 5×5 boxes. The resulting image reveals five interference fringes in the chosen section.

In order to quantify the fringe contrast we perform a vertical sum (along the y direction) over all rows and arrive at the one-dimensional interference curve. Since the statistical fluctuations are still rather high, with only 1166 molecules per μm^2 , we sum over 20 horizontal points (along the x direction) to obtain Fig. 3(b). The data are well represented by a numerical fit of the form $F(x) = A \sin(2\pi x/d + \phi_0) + B$, from which we extract a fringe visibility of $V = A/B = 36 \pm 3\%$. The statistical error is computed from a Levenberg-Marquardt algorithm which is weighted with the Poissonian uncertainty of each individual column of the raw data in Fig. 3(a). A similar interference contrast was found in the gravitational velocity selection scheme. This value is lower than the theoretical expectation, but already a linear drift of 2.5 nm per minute of either one grating or the surface is sufficient to explain this observation. In future experiments, thermal drifts can be further reduced by replacing the interferometer support structure by materials of lower thermal expansion.

The recorded lattice has a period of 267(3) nm which differs slightly from the expected 257 nm. The 4% period mismatch is consistent with a linear thermal drift rate, now in the STM instead of the interferometer, as small as 0.4 nm per minute. The experiment was repeated several times,

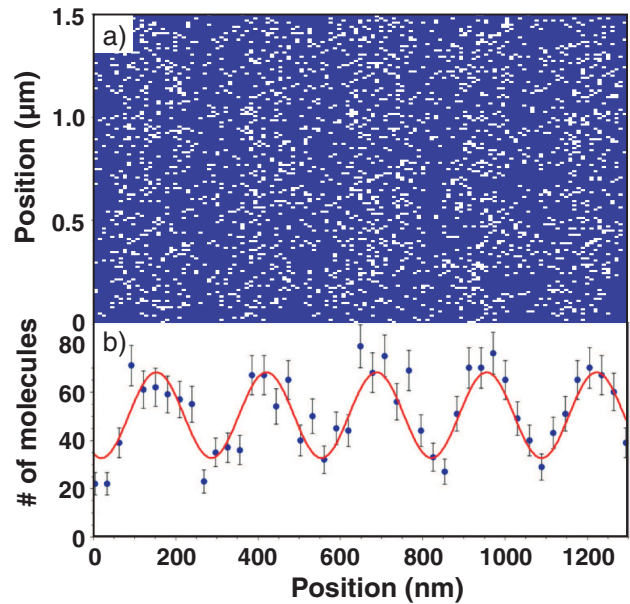


FIG. 3 (color). (a) The processed STM image (see text) reveals both the particle nature and the quantum wave nature of the surface-deposited fullerene molecules in one and the same image. (b) A vertical sum over (a) yields the interference curve. The fringe visibility amounts to 36%. The error bars represent the \sqrt{N} noise related to the small number N of particles per bin.

yielding an interference pattern equally close to the expected period and orientation.

The observed fringe contrast exceeds the classical moiré expectation in the presence of van der Waals forces by more than a factor of 30, and the experiment is offset from the classical result by 10 standard deviations. Quantum delocalization and interference are therefore needed for creating high-contrast molecular nanopatterns using non-contact mask imaging. Surface adsorption and imaging is also an intuitive tool in experiments on the foundations of physics, as it allows to visualize the localized but random particle positions within a deterministic fringe pattern that is prescribed by the free evolution of the delocalized matter wave (Fig. 3). The surface probe technique is capable of detecting individual molecules and it is well-suited for future experiments with velocity selected, monodisperse beams of much larger objects in different interferometer configurations [26].

Single molecules may be regarded as functional elements. They may serve as immobilized single-photon emitters [29], organic switches [30], nanomachines [31,32], transistor components [33] or as nucleation cores for the catalysis of molecular growth. Positioning them on surfaces might thus be crucial in future applications in nanotechnology. Our molecule lithography scheme works at a de Broglie wavelength comparable to that prevailing in high-energy electron beam writing. The kinetic energy $E_{\text{kin}} = 0.1 \text{ eV}$ and the velocity $v = 100 \text{ m/s}$ can, however, be many orders of magnitude smaller than that of

the electrons. It therefore combines the potential of high resolution with minimal damage to the surface.

Future experiments shall explore how to build more complex molecular patterns in this noncontact, constructive, and parallel way. High-contrast interference provides the possibility to exclude molecules with certainty from some surface areas. The positioning within an interference maximum is, however, still affected by the probabilistic character of the quantum wave function. The combination of interferometric prestructuring with local self-organization or STM postprocessing [34] appears to be a way towards deterministic molecular nanostructures [35]. Our present proof-of-principle demonstration shows the interferometric generation of molecular lines. Using two-dimensional cross gratings and either electric deflectometry [36] or motorized gratings it will be possible to write periodic arrays of more complex patterns, too [37]. In an asymmetric Talbot-Lau interferometer the exploitation of the fractional Talbot effect shall further allow writing of structures smaller than the grating period [38], eventually smaller than all features in the lithography masks.

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